

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	1405	organometallic and sublimation	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/30 12:02
S2	546	thin adj film and S1	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/30 09:14
S3	441	solvent and S2	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/30 09:17
S4	0	gassification and S3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/30 09:15
S5	224	chamber and S3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/30 09:15
S6	332	(chamber or apparatus or vessel) and S3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/30 09:17
S7	2	("6440495").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/11/30 12:00
S8	1206	organometallic and sublimation and ((lead or pb or zr or zirconium or ba or barium or sr or strontium or ta or tantalum or bi or bismuth))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/30 12:44
S9	487	(sublimation or gassification) and thin adj film and S8	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/30 12:45

S10	127	(pzt or bst or ta?) and S9	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/30 13:03
S11	4	tiipro adj dpm or badpm or srdpm or taoet or pbdpm or zrdpm or bidpm	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/30 13:04